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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/055,608	01/23/2002	Wolfgang Singer	637.0017USU	6642	
7590 04/22/2004 Charles N.J. Ruggiero, Esq. Ohlandt, Greeley, Ruggiero & Perle, L.L.P. 10th Floor One Landmark Square			EXAMINER		
			PRITCHETT, JOSHUA L		
			ART UNIT	PAPER NUMBER	
			2872		
Stamford, CT	06901-2682		DATE MAILED: 04/22/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/055,608	SINGER ET AL.				
Office Action Summary	Examiner	Art Unit				
	Joshua L Pritchett	2872	Au			
The MAILING DATE of this communication app Period for Reply	ars on the cover she t with the c	orr spond nc add	iress			
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be timed within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	nely filed s will be considered timely the mailing date of this co				
Status						
1) Responsive to communication(s) filed on 26 M	arch 2004.					
2a) ☐ This action is FINAL . 2b) ☑ This	☐ This action is FINAL . 2b)☑ This action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	33 O.G. 213.				
Disposition of Claims						
4)⊠ Claim(s) 26-73 and 75-78 is/are pending in the	4) Claim(s) 26-73 and 75-78 is/are pending in the application.					
· · · · · · · · · · · · · · · · · · ·	4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) <u>52-73 and 76</u> is/are allowed.						
6) Claim(s) 26-28,31-33,37,40,43-48,50,51,75,77	6) Claim(s) <u>26-28,31-33,37,40,43-48,50,51,75,77 and 78</u> is/are rejected.					
7) Claim(s) <u>29,30,34-36,38-40 and 49</u> is/are object	cted to.					
8) Claim(s) are subject to restriction and/or	r election requirement.					
Application Papers						
9) The specification is objected to by the Examine	r.					
10)⊠ The drawing(s) filed on <u>23 January 2002</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.						
Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	e 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the correct	ion is required if the drawing(s) is obj	ected to. See 37 CF	R 1.121(d).			
11)☐ The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PT	O-152.			
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority documents 3. See the attached detailed Office action for a list	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	on No ed in this National \$	Stage			
•						
Attachment(s)	. 🗖					
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date S Patent and Trademark Office.	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	ate	-152)			

DETAILED ACTION

This action is in response to Request for Continued Examination filed March 26, 2004 and Amendment filed February 27, 2004. Claims 26, 73 and 75 have been amended, claims 76-78 have been added and claim74 has been cancelled as requested by the applicant.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 26-28, 31-33, 37, 41 and 43 are rejected under 35 U.S.C. 102(b) as being anticipated by Murtha (US 5,002,379).

Regarding claim 26, Murtha discloses a collector comprising a first mirror shell for receiving a first ring aperture section of the light and the irradiating a first planar ring section of the plane with a first irradiance (Fig. 20), a second mirror shell for receiving a second ring aperture section of the light and the irradiating a second planar ring section of the plane with a second irradiance (Fig. 20). Murtha further discloses the first and second ring aperture sections do not overlap with one another (Fig. 19). Murtha further discloses the first planar ring section substantially abuts the second planar ring section (Fig. 18). Murtha further discloses the fist

irradiance is approximately equal to the second irradiance and the collector has a focal point (Fig. 20). Fig. 20 shows only one means of illumination and the first and second mirror shells have the same reflective power. Therefore the first and second irradiance are approximately equal.

Regarding claim 27, Murtha discloses the first and second mirror shells have dimensions that are different from one another in a direction of the axis of rotation (Fig. 19).

Regarding claim 28, Murtha discloses the first mirror shell is an inner mirror shell and the second mirror shell is an outer mirror shell (Fig. 19). Murtha further discloses the outer mirror shell is further distant from the plane than the position of the inner mirror shell based on a mean value of an initial and end point with regards to the axis of rotation for each mirror shell.

Regarding claim 31, Murtha discloses the first and second planar ring sections have radial dimensions of equal size (Fig. 18), the first and second planar ring sections are concentric (Fig. 18), the first planar ring section is an inner planar ring section and the second planar ring section is an outer planar ring section (Fig. 18), the first and second mirror shells have a dimension in the direction of the axis of rotation (Fig. 19), the dimension of the first mirror shell is larger than the dimension of the second mirror shell (Fig. 20).

Regarding claim 32, Murtha discloses the first and second mirror shells are each a ring-shaped segment of an aspherical object (Fig. 19).

Regarding claim 33 Murtha discloses the first and second mirror shells are a ring-shaped segment of a hyperboloid (abstract).

Regarding claim 37, Murtha discloses the first and second ring aperture segments are separated by a gap (Fig. 20).

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Regarding claim 41, Murtha discloses wherein the first and second mirror shells are two of a plurality of at least three mirror shells (Fig. 18).

Regarding claim 43, Murtha discloses an illumination system comprising the collector (Fig. 20).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 44, 45 and 78 are rejected under 35 U.S.C. 103(a) as being unpatentable over Murtha in view of Schultz.

Murtha teaches the invention as claimed but lacks reference to the use of raster elements. Schultz teaches the use of raster elements in EUV lithography (col. 2 lines 39-40). It would have been obvious to a person of ordinary skill in the art at the time the invention was made to have the Murtha collector contain the raster elements taught by Schultz for the purpose of providing extra versatility to the EUV lithography design.

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Claims 46-48, 50, 51, 75 and 77 are rejected under 35 U.S.C. 103(a) as being unpatentable over Murtha in view of Schultz as applied to claim 44 above, and further in view of Chapman.

Regarding claim 46, Murtha teaches the invention as claimed but lacks reference to the use of using the collector in the claimed illumination system. Chapman teaches the illumination system has a second optical element for imaging (Fig. 6, 610). It would have been obvious to a person of ordinary skill in the art at the time the invention was made to use the Murtha nested collector in an illumination system as taught by Chapman for the purpose of efficiently directing extreme ultraviolet light onto a lithography wafer.

Regarding claim 47, Murtha teaches the invention as claimed but lacks reference to the use of using the collector in the claimed illumination system. Chapman teaches the second optical element is used for field shaping (col. 7 lines 7-8). It would have been obvious to a person of ordinary skill in the art at the time the invention was made to use the Murtha nested collector in an illumination system as taught by Chapman for the purpose of efficiently directing extreme ultraviolet light onto a lithography wafer.

Regarding claims 48, 75 and 77, Murtha teaches the invention as claimed but lacks reference to the use of using the collector in the claimed illumination system. Chapman discloses an illumination system wherein the system comprises a second plan conjugated to the light source between the collector and the first plane in which an intermediate image of the light source is formed (Fig. 6, 610). It would have been obvious to a person of ordinary skill in the art at the time the invention was made to use the Murtha nested collector in an illumination system

as taught by Chapman for the purpose of efficiently directing extreme ultraviolet light onto a lithography wafer.

Regarding claim 50, Murtha teaches the invention as claimed but lacks reference to the use of using the collector in the claimed illumination system. Chapman discloses an EUV projection system with a mask and a projection objective (col. 4 lines 33-45). It would have been obvious to a person of ordinary skill in the art at the time the invention was made to use the Murtha nested collector in an illumination system as taught by Chapman for the purpose of efficiently directing extreme ultraviolet light onto a lithography wafer.

Regarding claim 51, Murtha teaches the invention as claimed but lacks reference to the use of using the collector in the claimed illumination system. Chapman discloses a process for producing a microelectronic device comprising EUV projection exposure (col. 4 lines 33-45). It would have been obvious to a person of ordinary skill in the art at the time the invention was made to use the Murtha nested collector in an illumination system as taught by Chapman for the purpose of efficiently directing extreme ultraviolet light onto a lithography wafer.

Allowable Subject Matter

Claims 52-73 and 76 are allowed.

The following is an examiner's statement of reasons for allowance:

Regarding claim 73, the prior art of record fails to teach or suggest the use of a diaphragm near an intermediate image separating the light source and the collector from a portion of the illumination system.

Regarding claim 76, the prior art of record fails to teach or suggest the nested collected having a central aperture with a numerical aperture of less than or equal to 0.30.

Claims 52-72 are allowable for reasons discussed in the previous office actions.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Claims 29, 30, 34-36, 38-40 and 49 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is a statement of reasons for the indication of allowable subject matter: the reasons for indicating allowable subject matter as the same as provided in the previous office actions.

Response to Arguments

Applicant's arguments, see Amendment, filed February 27, 2004, with respect to the rejection(s) of claim(s) 26 under Chapman have been fully considered and are persuasive.

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Therefore, the rejection has been withdrawn. However, upon further consideration, a new

ground(s) of rejection is made in view of Murtha.

Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Joshua L Pritchett whose telephone number is 571-272-2318.

The examiner can normally be reached on Monday - Friday 7:00 - 3:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Drew A Dunn can be reached on 571-272-2312. The fax phone number for the

organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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